



IFW

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

MARKUS NOPPER
AXEL PREUSSE

Serial No.: 10/602,192

Filed: June 24, 2003

For: METHOD OF FORMING A METAL
LAYER OVER A PATTERNED
DIELECTRIC BY ELECTROLESS
DEPOSITION USING A CATALYST

Examiner: Caridad Everhart

Group Art Unit: 2825

Att'y Docket: 2000.106500/DE0260

Customer No.: 23720

RESPONSE TO OFFICE ACTION DATED FEBRUARY 11, 2005

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

CERTIFICATE OF MAILING
37 C.F.R 1.8

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date below:

April 12, 2005

Date



Signature

This paper is submitted in response to the Office Action dated February 11, 2005, for which the three-month date for response is May 11, 2005.

No fees are believed to be due in connection with the present paper. **However, should any fees be required under 37 C.F.R. §§ 1.16 to 1.21, the Director is authorized to deduct such fees from the Advanced Micro Devices, Inc. Deposit Account No. 01-0365/DE0260.** In the event the monies in that account are insufficient, the Director is authorized to withdraw funds from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2000.106500.

Reconsideration of the application in view of the following amendments and remarks is respectfully requested.